## xp002138246

Skin preparations calcaining surfactants or modurizers from Pseudomonas TI species

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SO Jpn. Kokai Tokkyo Koho, 6 pp.

CODEN: JKXXAF

DT Patent

Japanese LA

IC ICM A61K007-00

> A61K007-48; B01F017-00; C12P001-04 ICS

ICI C12P001-04, C12R001-38

CC 62-4 (Essential Oils and Cosmetics)

Section cross-reference(s): 16

FAN.CNT 1

PATENT NO. KIND DATE APPLICATION NO. DATE

P.D. ....

PΙ JP 08208427 A2 19960813 AB Skin prepns. contain surfactants or moisturizers from Pseudomonas sp. or their exts. P. putida was cultured in a medium contg. glycine betaine, yeast ext., pyruvic acid, and salts at 27.degree. for 48 h to produce surface-active substance, which (3.0 wt.%) was mixed with dipropylene glycol 2.0, glycerin 3.0, H2O 34.0, cetanol 8.0, jojoba oil 5.0, squalane 27.5, silicone 15.0 wt.%, perfume, and antiseptic to prep. a cream. The cream gave luster, moisture, and smoothness to the skin.

ST skin prepn surfactant moisturizer Pseudomonas

IT Fermentation

Pseudomonas

Pseudomonas putida

Surfactants

(skin prepns. contq. surfactants or moisturizers from Pseudomonas sp.) IT Cosmetics

(conditioners, skin prepns. contg. surfactants or moisturizers from Pseudomonas sp.)

BNSDOCID: <XP\_\_\_2138246A\_\_t\_>

JP 1995-17635

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